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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the	e Application of:	1
SUNG-KWON LEE		Art Group
Application No.:		Examiner:
Filed:		l),
For:	METHOD FOR FABRICATING SEMICONDUCTOR DEVICE USING ARF PHOTOLITHOGRAPHY CAPABLE OF PROTECTING TAPERED PROFILE OF HARD MASK	

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

TRANSMITTAL OF FORMAL DRAWINGS

Sir:

Enclosed herewith for filing in the above-identified U.S. Patent Application are the formal drawings, 12 sheets including 20 Figures. Please charge any additional fees or credit any overpayment to Deposit Account No. 02-2666. A duplicate copy of the Fee Transmittal is enclosed for this purpose.

Respectfully submitted,

Blakely, Sokoloff, Taylor & Zafman LLP

Dated:

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